

# METHOD FOR MANUFACTURING INDIUM COMPLEX OR ITS TAUTOMER

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## Abstract of JP2002105055

**PROBLEM TO BE SOLVED:** To provide a method for manufacturing an indium complex compound useful as a material for a light emission element, especially various kinds of ortho-metalated complex of indium (III) which are particularly useful, easily in high yield.  
**SOLUTION:** A method for manufacturing an ortho-metalated complex of indium (III) using an indium complex having a specific structure or its tautomer as a raw material.

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